(*) Indicates that there are additional or special requirements, consult the end of the document



Santa Cruz de Marcenado, 27 28015 Madrid - España.

Fashion Design

Integrated Programme in Communication Sciences International offering 2024-2025

FIRST SEMESTER (September to January only)

ECTS	Acad. Year	Course Name	Language
6	1	Fundamentals of Design	Spanish
6	1	Pattern design and Dressmaking 1	Spanish
6	1	Artistic drawing 1	Spanish
6	1	History of the Garment and Fashion Sociology 1 *	Spanish C1
6	1	Professional Competence Development Seminar I	English
6	2	Vector Design 2 *	Spanish
6	2	Pattern design and Dressmaking 3 *	Spanish / English
6	2	Representation Techniques *	Spanish
6	3	Fashion design 3 *	Spanish C1
6	3	Fashion Illustration *	Spanish
6	3	Styling	Spanish
6	3	Male pattern design *	Spanish C1
6	4	Modeling 2 *	Spanish C1
6	4	Project and Digital Editing (FF) *	Spanish C1

SECOND SEMESTER (January to May / June only)

ECTS	Acad. Year	Course Name	Language
6	1	Fashion Design 1 *	Spanish C1
3	1	Artistic drawing 2 *	Spanish
6	1	Vector Design 1	Spanish
6	1	Pattern design and Dressmaking 2 *	Spanish / English
6	1	Visual and aesthetic culture *	Spanish C1
6	2	Fashion Design 2 *	Spanish C1
6	2	Trends and Communication in Fashion *	Spanish C1
6	2	Professional Competence Development Seminar II	English
6	3	Modeling 1 *	Spanish C1
3	3	Cinema and Theater Clothing *	Spanish C1
3	4	Styling	Spanish
6	4	Illustration of Mixmedia project *	Spanish
3	4	Fashion industry *	Spanish C1

* ANNOTATIONS AND SPECIAL REQUIREMENTS:

History of the Garment and Fashion Sociology 1 C1-level in Spanish is required to enroll in this subject. Vector Design 2 Necessary to have taken Vectorial Design I or equivalent knowledge from the home university. Also required: ability with Adobe Package.

Pattern design and Dressmaking 3

C1-level in Spanish is required to enroll in this subject. Required to have done Pattern Making and Tailoring 2, or have intermediate knowledge in pattern making from the home university.

Representation Techniques

Required to have done Artistic Drawing 1 or 2, or have intermediate level drawing knowledge from studies at the home university.

Fashion design 3

Required to have taken Pattern Making and Tailoring 3, or a high level of pattern making and tailoring due to studies from home university.

Fashion Illustration

Requires having done Artistic Drawing, necessary to have a high level of drawing ability Male pattern design

Required to have taken Pattern Making and Tailoring 3, or a high level of pattern making and tailoring due to studies from home university.

Modeling 2

Required to have basic ability of modeling on mannequins, in addition to a high level of pattern making and tailoring from the university of origin.

Project and Digital Editing (FF)

C1-level in Spanish is required to enroll in this subject.

Fashion Design 1

Required to have done Pattern Making and Tailoring 1, or have basic knowledge in pattern making from the home university.

Artistic drawing 2

Required to have done Artistic Drawing 1, or have basic level drawing knowledge from studies at the home university.

Pattern design and Dressmaking 2

C1-level in Spanish is required to enroll in this subject. Required to have done Pattern Making and Tailoring 1, or have basic knowledge in pattern making from the home university.

Fashion Design 2

Required to have done Pattern Making and Tailoring 2 or 3, alternatively, you could substitute with intermediate knowledge in pattern making and tailoring from the home university.

Trends and Communication in Fashion

C1-level in Spanish is required to enroll in this subject.

Modeling 1

It requires having a high-level pattern making and tailoring skill.

Cinema and Theater Clothing

It requires having a high-level pattern making and tailoring skill.

Styling

It would be essential to confirm the capacity of the classroom, it could only be attended 100% in person.

Illustration of Mixmedia project

You must have notions of drawing and illustration, and Adobe package.

Fashion industry

C1-level in Spanish is required to enroll in this subject.